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Photo-oxidation of Nitroso-compounds: Dissociative Mechanism for the Photo-oxidation of 2-Methyl-2-nitrosobutane

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Summary The photo-oxidation of 2-methyl-2-nitrosopropane in the gas phase is shown to proceed by a dissociative mechanism via peroxyl and alkoxyl radicals and to provide a model system for the study of the oxidation of low levels of NO to NO₂, which is of interest in studies of reactions occurring in photochemical smog.

THE photo-oxidation of nitrosoalkanes is reported to proceed via an intermediary diradical adduct (2) of O_2 to an excited state of the nitroso-compound leading either to quantitative formation of nitro-compounds in inert solvents¹⁻³ or to products explained by addition and abstraction reactions of (2)^{3,4} in more reactive solvents. Recent

$$\begin{array}{c} & & & \\ & & & \\ \text{RNO} \xrightarrow{h\nu} \text{RNO}^* \xrightarrow{+ O_2} & | \\ & & \text{RNOO} \\ (1) & & & (2) \end{array}$$
(1)

independent work appears to confirm a mechanism in which adducts (2) are formed.⁵ On the other hand the photooxidation of *gem*-chloronitroso-compounds proceeds *via* photodissociation of (1) exclusively⁶ and it is also known that the photo-oxidation of optically active (1) leads to formation of the racemic nitro-compound suggesting a dissociation-inversion-recombination sequence prior to formation of the oxidation product.⁷

The results of a study of the photo-oxidation of 2-methyl-2-nitrosopropane ($Bu^{t}NO$) in the gas phase reported here indicate that reaction (1) is unimportant.

When 10—100 mTorr of gaseous Bu^tNO were photolysed to completeness in the presence of a 10⁴—10⁵-fold excess of oxygen by brief exposure to intense 540—800 nm radiation[†] corresponding to the $n^* \rightarrow \pi^*$ absorption of the nitrosochromophore, the main product (62%) was t-butyl nitrate as indicated by the i.r. bands of the product vapour at 1647 and 1309 cm⁻¹. Direct g.l.c. analysis of the vapour

† The high intensities were achieved by operating a 400 W sodium lamp in the centre of a large silvered vessel in order to exploit multiple reflection of the emitted light.

revealed that the other products included acetone (18%), 2-methyl-2-nitropropane (14%), t-butyl nitrite (2%), and isobuty ene (2%). Similar results were obtained in the presence of 5-10 Torr of O₂ and 750 of Torr N₂.

Mechanism $(1)^3$ requires that the nitro-compound be formed as the main product at sufficiently high $[O_2]$ to [ButNO] ratios. The complicated product pattern obtained in this work rules out mechanism (1), however, and can only be rationalised adequately by a mechanism based on an initial photodissociation of the C-N bond of (1) since 86% of the products do not contain this bond. The t-butyl radicals formed in the primary step (2) will react with O_2 virtually exclusively under the experimental conditions chosen, and will give rise to t-butoxyl radicals via the sequence (3).

$$\operatorname{Bu^{t}NO} \xrightarrow{h\nu} \operatorname{Bu^{t}NO^{*}} \rightarrow \operatorname{Bu^{t.}} + \operatorname{NO}$$
(2)

$$\operatorname{Bu}^{t} \xrightarrow{+\operatorname{O}_{2}} \operatorname{Bu}^{t}\operatorname{O}_{2} \xrightarrow{+\operatorname{NO}} \operatorname{Bu}^{t}\operatorname{O}_{2} + \operatorname{NO}_{2}$$
(3)

The importance of alkoxyl radical formation is evident from the fact that 82% of the products are directly derived from the combination and fragmentation reactions of this radical (Scheme). Confirmatory evidence was obtained from a study of the photo-oxidation of Bu^tNO in the presence of 5 Torr of O2 and 750 Torr of N2 containing 100 p.p.m. of NO. These conditions excluded significant conversion of NO into NO2 by the usual slow thermal oxidation of NO and resulted in a twentyfold increase of the yield of Bu^tONO at the expense of all other products as predicted by the Scheme.

Reactions analogous to (3) are of importance in the con-

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version of NO into NO₂ in photochemical smog.^{8,9} The generally accepted view, that the important reaction of methylperoxyl radicals with NO produces NO₂ and CH₃O· has been questioned.¹⁰ The effect of the small amounts of



added NO found in this work, however, shows unambiguously that t-butylperoxyl radicals react as in reaction (3) rather than by the proposed alternative combination,¹⁰ a conclusion which is in agreement with the results of the most recent reinvestigation of the reaction of the methylperoxyl radical with NO.¹¹ It is thus apparent that the photooxidation of nitrosoalkanes provides a model system for the study of the oxidation of low levels of NO to NO₂ by alkylperoxyl radicals which is complementary to and in some aspects more advantageous than the photo-oxidation of azoalkanes,^{10,11} both methods being based on the photochemical production of alkyl radicals in the presence of O_2 . The excited state mechanism proposed in the earlier work¹⁻⁵ for the photo-oxidation of nitrosoalkanes is ruled out by the present study.

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